

Electronic Patent Application Fee Transmittal

Application Number:	10549901			
Filing Date:	20-Sep-2005			
Title of Invention:	SUBSTRATE FOR RETICLE AND METHOD OF MANUFACTURING THE SUBSTRATE, AND MASK BLANK AND METHOD OF MANUFACTURING THE MASK BLANK			
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Attorney Docket Number:	Q90414			
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Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
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Miscellaneous-Filing:				
Petition:				
Patent-Appeals-and-Interference:				
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Utility Appl issue fee	1501	1	1510	1510
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